Errata

Journal of Materials Science Letters, Volume 15, Number 4 (1996) 343-344

Phosphorous and boron doping effects on solid phase recrystallization of polycrystalline silicon films amorphized by germanium ion implantation

The first authors initials were printed incorrectly, and the correct name is printed below.

M.-K. KANG, T. YAMAMOTO, T. MATSUI, H. KUWANO

Journal of Materials Science Letters, Volume 15, Number 10 (1996) 827-830

Electron beam welding and post-weld treatments of steels

All the authors names were printed incorrectly, and the correct names are printed below.

S. TOSTO, F. NENCI, M. DE MARTINO